

	Application No.	Applicant(s)		
	10/624,678	624,678 SUGITA ET AL.		
Notice of Allowability	Examiner	Art Unit		
	Rip A. Lee	1713		
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this apport or other appropriate communication GHTS. This application is subject to	olication. If not include will be mailed in due	ed course. THIS	
1. This communication is responsive to <u>August 31, 2005</u> .				
2. The allowed claim(s) is/are 1-9 and 11-16.				
3. Acknowledgment is made of a claim for foreign priority unexample as the application number (see 37 CFR 1 arch cheet Replacement should be leached as such in the leached as such in	been received. been received in Application No cuments have been received in this r of this communication to file a reply of IENT of this application. itted. Note the attached EXAMINER' es reason(s) why the oath or declarate of the submitted. Son's Patent Drawing Review (PTO-6) s Amendment / Comment or in the Of .84(c)) should be written on the drawing.	national stage applicational stage applicational stage application of the front (not the last in the front (not the	quirements	
each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d). 6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.				
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Attachment(s)			• 450	
1. Notice of References Cited (PTO-892)	5. Notice of Informal P	• • • • • • • • • • • • • • • • • • • •	J-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No./Mail Dat	, , , , , , , , , , , , , , , , , , ,		
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0				
Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. X Examiner's Stateme	8. Examiner's Statement of Reasons for Allowance		
	9. Other			
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EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Steven B. Kelber on November 9, 2005.

Claims 11, 13, and 15:

In each claim, replace the figure with the figure shown below (brackets and integer n have been removed).

Claim 13, line 8 delete "and n is 0 or 1,"

Claim 15, line 8 delete "and n is 0 or 1,"

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Allowable Subject Matter

The following is an examiner's statement of reasons for allowance: Claims 1-9 and 11-16 are allowed.

The present invention is drawn to a polymer containing a structural unit of formula (3) (see claims for details). The structural unit is derived from an acenaphthylene monomer containing a $-CH_2-OR^1$ group. The M_w of the polymer lies in the range of 500-10,000. Antireflection film forming compositions derived from the polymer also lie within the scope of the invention.

Another aspect of the invention is an Anti-reflection film forming composition having a structural unit (4). The structural unit is derived from a vinyl naphthalene monomer containing a -CH₂-OR⁴ group.

A further aspect of the invention is an Anti-reflection film forming composition comprising a polymer having structural units (3) and (4), a polymer having structural units (3) and (5), or a polymer having structural units (4) and (5), where (5) is a monomer unit derived from acenaphthylene.

Another aspect of the invention is a claim to the compounds acetoxymethylacenaphthylene (1) and hydroxymethylacenaphthylene (2).

Murata et al. (JP 6-161111), Eichorn et al. (U.S. 5,654,121), Yamada et al. (WO 01/13179), Shimokawa et al. (JP 9-230596), Shimokawa et al. (JP 8-184966), Kizu et al. (JP 10-090885) have been cited previously as closest prior art. The references disclose films derived from polymer containing styrene monomer units in which the aromatic ring is substituted with a -CH₂-OR group. None of the references discloses polymers containing units derived from corresponding vinylnaphthalene monomers.

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Carpino et al. (J. Org. Chem., 1964) discloses the compound 5,6-acenaphtylene-

dimethanol. This compound is analogous to compound (2), except there are two hydroxymethyl

groups instead of only one, as claimed.

Kawaguchi et al. (EP 1 205 805; U.S. 2002/0086934) discloses polymers derived from

acenaphthylene derivatives in which substituent R¹ is hydrogen, alkyl, alkenyl, hydroxyl, amino,

phenyl, acyl, carboxyl, sulfonic acid, mercapto, etc. The reference does not disclose or

reasonably suggest use of -CH₂-OR groups.

Any comments considered necessary by applicant must be submitted no later than the

payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Rip A. Lee whose telephone number is (571)272-1104. The examiner can be reached on Monday through Friday from 9:00 AM - 5:00 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Wu, can be

reached at (571)272-1114. The fax phone number for the organization where this application or

proceeding is assigned is (571)273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on the access to the

Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll free).

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November 10, 2005

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SUPERVISORY PATENT EXAMINER
TECTION OLDGY CENTER 1700